2.4 MOSFET (Metal Oxide Semiconductor Field Effect Transistor)

- Like JFET, it has a source, Drain and Gate.
- It is also called IGFET (Insulated Gate FET) because gate terminal is insulated from channel. Therefore it has extremely high input resistance.

Types of MOSFET

- Depletion mode MOSFET
 - N-channel
 - P-channel
- Enhancement mode MOSFET
 - N-channel
 - P-channel

The enhancement-type MOSFET is usually referred to as an E-MOSFET, and the depletion type, a D-MOSFET. The drain current in a MOSFET is controlled by the gate-source voltage VGS.

Depletion mode-MOSFET [D-MOSFET]

In depletion mode of operation the bias voltage on the gate reduce the number of charge carriers in the channel and therefore reduce the drain current ID.It operates in both depletion mode and enhancement mode.

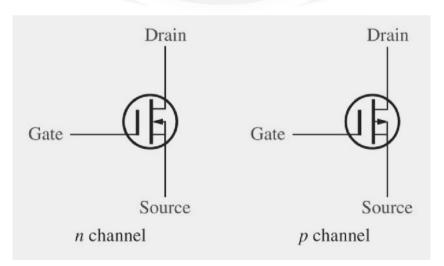


Figure 2.4.1 D-MOSFET symbol for n-channel and p-channel

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 90]

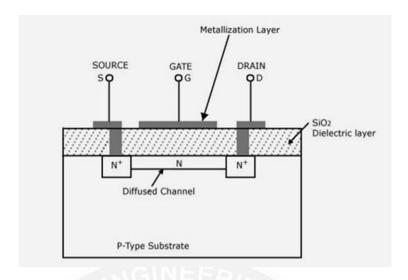


Figure 2.4.2 D-MOSFET n-channel and p-channel

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 90]

- It consists of lightly diffused. Doped p-type substrate in which two highly doped n-regions are
- The source and drain terminals are connected through metallic contacts to n-doped regions linked by an n-channel. The gate is also connected to a metal contact surface but remains insulated from the n-channel by a very thin silicon dioxide (SiO2) layer. SiO2 is a particular type of insulator referred to as a dielectric that sets up opposing (as revealed by the prefix di-) electric fields within the dielectric when exposed to an externally applied field.
- Then the thin layer of metal aluminum is formed over the Sio2 layer. This metal overs the entire channel region and it forms the gate (G).

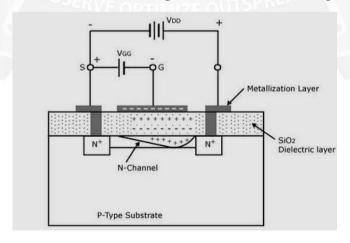


Figure 2.4.3 n-channel D-MOSFET under applied bias

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 91]

Case (i) "when and is increased from zero"

Here N-base (Drain) is connected to positive supply. It act as a reverse bias. Due to this, depletion region gets increases.

Free electron from n-channel are attracted towards positive potential of drain terminal.

This establishes current through channel flows from drain to source and denoted as IDSS.

Pinch of voltage

The pinch off voltage is the voltage at which the junction is depleted of charge carriers.

Case (ii) "when and is increased from zero"

- The negative charge on gate repels conduction electrons from the channel and attract holes from the p-type substrate.
- Due to this electron-hole recombination occurs and reduce the number of free electrons in the channel available for conduction, reducing Drain current (ID).
- When negative voltage of is increased the pinch of voltage decreased. When
 is further increased the channel is fully depleted and no current flows through
 it.
- The negative voltage depletion MOSFET.

Characteristics curve

- Drain characteristics
- Transfer characteristics

D-MOSFET's are biased to operate in two modes:

Depletion or Enhancement mode.

ENHANCEMENT- MODE MOSFET [E-MOSFET]

• In this mode bias on the gate increases the number of charge carriers in the channel and increases the drain current (ID).

• It operates only in the enhancement mode and has no depletion mode of operation. It has no physical channel

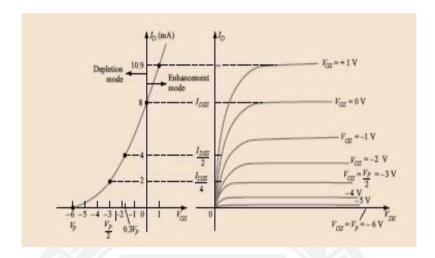


Figure 2.4.4 Drain and transfer characteristics

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 91]

Symbol of E-MOSFET

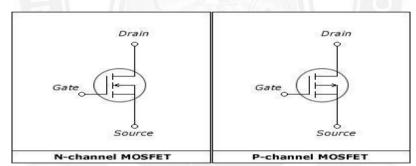


Figure 2.4.5 symbol of n-channel and p-channel E-MOSFET

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 98]

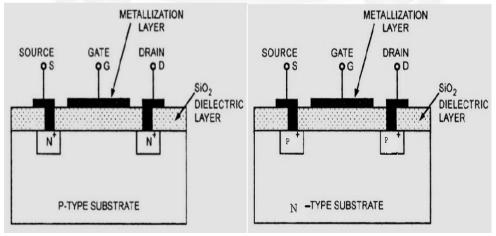


Figure 2.4.6 Construction of n-channel and p-channel E-MOSFET

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 98]

In the basic construction of the n-channel enhancement-type MOSFET, a slab of p-type material is formed from a silicon base and is again referred to as the substrate. As with the depletion-type MOSFET, the substrate is sometimes internally connected to the source terminal, while in other cases a fourth lead is made available for external control of its potential level.

The SiO₂ layer is still present to isolate the gate metallic platform from the region between the drain and source, but now it is simply separated from a . Section of the p-type material.

In summary, therefore, the construction of an enhancement-type MOSFET is quite similar to that of the depletion-type MOSFET, except for the absence of a channel between the drain and source terminals.

Operation

- If VGS is set at 0 V and a voltage applied between the drain and source of the device, the absence of an n-channel (with its generous number of free carriers) will result in a current of effectively zero amperes—quite different from the depletion- type MOSFET and JFET where ID IDSS.
- It is not sufficient to saturation level as occurred for the JFET and depletion-typeMOSFET.
- The conductivity of the channel is enhanced by the positive bias voltage on the gate, the device is known as enhancement MOSFET. E-MOSFET's are normally called as -OFF MOSFET

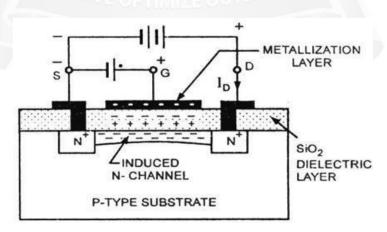


Figure 2.4.7 N-channel E-MOSFET under applied bias

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 99]

Characteristics of E-MOSFET

Drain characteristics curve

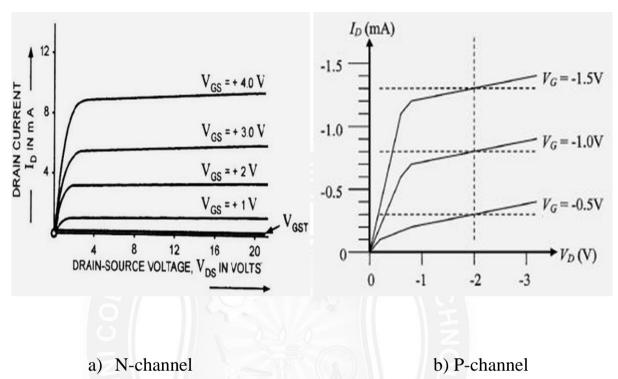


Figure 2.4.8 Drain characteristics curve a) n-channel b) p-channel

[Source: "Electronic devices and circuits" by "Balbir Kumar, Shail.B.Jain, and Page: 101]

